

Beat: Technology

Side By Side (The Documentary) - The Digital Revolution by KEANU REEVES

Master Class by OCS Chanel in PARIS

PARIS, 16.04.2016, 15:01 Time

USPA NEWS - Keanu Reeves spent twenty four hours in PARIS giving an exceptional Master Class in Royal Monceau (PARIS) on April 12, 2016. Journalists could listen to the one who initiated the project of a Documentary dealing with the history, process and workflow of both digital and photochemical film creation.

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Title : Side by Side (2012 documentary film)

Directed by : Christopher Kenneally

Produced by : Keanu Reeves and Justin Szlasa

Starring : Keanu Reeves, John Malkovich, Danny Boyle, George Lucas, James Cameron, David Fincher, David Lynch, Robert Rodriguez, Martin Scorsese, Steven Soderbergh, The Wachowskis, Christopher Nolan, Joel Schumacher, Richard Linklater, Lars von Trier, Lena Dunham, Greta Gerwig, Caroline Kaplan..

Running Time : 98 minutes

Language : English

Country : United States

Released on : 2012 American Film premiered at the 62nd Berlin International Film Festival and it was shown at the Tribeca Film Festival

The story :

It shows what artists and filmmakers have been able to accomplish with both film and digital and how their needs and innovations have helped push filmmaking in new directions. Interviews with directors, cinematographers, colorists, scientists, engineers and artists reveal their experiences and feelings about working with film and digital

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